

**INFORMATION DISCLOSURE STATEMENT**

Applicant	:	Maruyama, et al.
App. No	:	10/522036
Filed	:	January 19, 2005
For	:	CHEMICAL AMPLIFICATION TYPE POSITIVE PHOTORESIST COMPOSITION AND RESIST PATTERN FORMING METHOD
Examiner	:	Lee, Sin J.
Art Unit	:	1752

Mail Stop Amendment  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Dear Sir:

Enclosed for filing in the above-identified application is a PTO/SB/08 Equivalent listing 2 references to be considered by the Examiner. Also enclosed is 1 foreign patent reference and/or non-patent literature as listed on the Information Disclosure Statement.

This Information Disclosure Statement is being filed after the mailing date of a final action or after the mailing date of a Notice of Allowance. This Statement is accompanied by the fee set forth in 37 C.F.R. § 1.17(p). The Commissioner is hereby authorized to charge any additional fees which may be required or to credit any overpayment to Account No. 11-1410.

**CERTIFICATION UNDER 37 C.F.R. § 1.97(e)(1)**

I hereby certify that each item of information contained in this Statement was first cited in a communication from a foreign Patent Office in a counterpart foreign application not more than

**Appl. No.** : 10/522036  
**Filed** : January 19, 2005

**Docket No.** SHIGA7.004APC  
**Customer No.** 20,995

three months prior to the filing of this Information Disclosure Statement.

Respectfully submitted,

KNOBBE, MARTENS, OLSON & BEAR, LLP

Dated: \_\_\_\_\_

2/22/07

By: \_\_\_\_\_

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<b>INFORMATION DISCLOSURE STATEMENT BY APPLICANT</b>	Application No.	10/522036
	Filing Date	January 19, 2005
	First Named Inventor	Maruyama, et al.
	Art Unit	1752
(Multiple sheets used when necessary)	Examiner	Lee, Sin J.
SHEET 1 OF 1	Attorney Docket No.	SHIGA7.004APC

U.S. PATENT DOCUMENTS					
Examiner Initials	Cite No.	Document Number Number - Kind Code (if known) Example: 1,234,567 B1	Publication Date MM-DD-YYYY	Name of Patentee or Applicant	Pages, Columns, Lines Where Relevant Passages or Relevant Figures Appear
	1.	6,673,512 B1	01-06-2004	Kazuya, et al.	

FOREIGN PATENT DOCUMENTS						
Examiner Initials	Cite No.	Foreign Patent Document Country Code-Number-Kind Code Example: JP 1234567 A1	Publication Date MM-DD-YYYY	Name of Patentee or Applicant	Pages, Columns, Lines Where Relevant Passages or Relevant Figures Appear	T <sup>1</sup>

NON PATENT LITERATURE DOCUMENTS			
Examiner Initials	Cite No.	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.	T <sup>1</sup>
	2.	Office Action dated January 10, 2007 in connection with Korean Patent Application No. 10-2006-7021725.	

3457989/LRR  
022207

Examiner Signature	Date Considered
<p><b>*Examiner:</b> Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.</p>	

T<sup>1</sup> - Place a check mark in this area when an English language Translation is attached.